

## A. Get access to the following paper

J. Bürger, V. Kunnathully, D. Kool, J. K. N. Lindner, K. Brassat, *nanomaterials* 10, 141 (2020)  
DOI:10.3390/nano10010141

## B. Answer the following questions

1. How many authors does the manuscript have?
2. How many references are given?
3. When was this paper published?
4. What is the name of the publisher and of the journal?
5. Is there any supplementary information available?
  
6. What is the basic topic of this paper and why is this field of research important to the world?
7. Which words describe the research presented here best?
8. Which analytical techniques can one use to investigate block copolymer nanostructures?
9. What is the knowledge gap which is to be filled with this research?
10. Where can I find more detailed information on the use of block copolymer lithography for photovoltaics?
  
11. Who is the supplier of the polymers?
12. Who is the manufacturer of the scanning electron microscope?
13. What information does reference 59 give?
14. How can the presented research be continued?
15. Which technique was used to acquire images in Figure 4?
16. What does STEM-ADF mean?
17. Which analytical techniques are used in this paper to investigate the samples?
18. What is the annealing temperature of the polymer films?